

Title (en)

PHOTORESISTIVE SILVER HALIDE PHOTOGRAPHIC MATERIAL

Publication

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Application

EP 88312348 A 19881228

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- JP 6553488 A 19880318
- JP 6912388 A 19880323
- JP 7121788 A 19880325
- JP 8360088 A 19880405
- JP 9608588 A 19880419
- JP 22400288 A 19880907
- JP 33393487 A 19871228

Abstract (en)

[origin: EP0323215A2] A photosensitive silver halide photographic material having a support and, provided thereon, the photographic component layers including at least one silver halide emulsion layer containing silver halide grains (1) having at least two kinds of halogens, is disclosed. The silver halide grains (1) are grown to in a system in the presence of silver halide grains (2) coexisting: with silver halide grains which are growing to the silver halide grains (1), for at least some portion of period that said silver halide grains are growing in the system, and comprising solubility product less than that of said growing silver halide grains.

IPC 1-7

G03C 1/02

IPC 8 full level

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CPC (source: EP)

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Citation (search report)

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- [Y] FR 2079012 A5 19711105 - FUJI PHOTO FILM CO LTD
- [Y] US 3342592 A 19670919 - FU-HUA CHU VICTOR, et al
- [A] PATENT ABSTRACTS OF JAPAN, vol. 12, no. 163 (P-703)[3010], 18th May 1988; & JP-A-62 278 543 (FUJI PHOTO FILM CO. LTD) 03-12-1987

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